

Surface materials engineering From R&D to large volume





HEF Photonics serves a variety of markets including:





Precision polishing:

Precision up to λ / 20 for diameters under 300 mm

• All types of materials: silica, sapphire, silicon, germanium, ceramics, quartz, zerodur...

 All types of shapes: windows, mirrors, prisms, lenses, beamsplitters, waveplates, filters and more

Polishing of dimensions up to 1000 mm

Glass fabrication technology:

- Chemical strenghtening
- Heat tempering
- Screen printing of Graphics
- · Laser-marked displays



Optical thin films:

Over 35 chambers dedicated to fulfill our customer requirement Technologies: Ebeam deposition, Ion Assisted Deposition, Sputtering evaporation, thermal CVD deposition.

Coating solutions are offered from 200nm in the UV to 20 microns in the far infrared

- Anti-reflective, metallic, dieletric coatings, beamsplitters, filters, polarizing coatings
- Multispectral coatings
- Internal (prism) or external
- Filters: broadband, narrow band
- Intense black coating
- Transparent conductive (ITO)
- Bus Bar
- Hydrophobic solutions
- High laser damage threshold coatings





Masking and lithography

Engraving using different types of technology (photolithography, lift-off, wet etching, laser)

- Masking and creation of complete optical components
- On substrates from 2" up to 8"
- Resolution down to 1µm in width and 0.15µm in thickness
- Different types of substrates and etched materials (Au, Al, Ag, Cr, Cu, Ni...)

Electroforming

- Nickel deposition, thickness from 30 to 200µm
- Circles, slits, closed shapes down to microns
- Coated for emission and reflection

Precision dicing

Technologies: laser, scribe cutting, waterjet, slicer, wafer dicing

- Glass, stacks, Si wafer, metals, plastics
- Thickness down to 50um
- Lateral roughness down to 3µm
- CNC machining





Contact

Philippe Goupilleau Business Development, Key Account Manager pgoupilleau@hef.group +33 (016 37 46 21 55

www.hef.fr

